

**Amendments to the Specification:**

Please replace the paragraph beginning at page 6, line 17, with the following amended paragraph:

A layer of an acrylic resin 102 is formed on this PET film 101. As an example, a methyl ester of acrylic acid can be used as the acrylic resin. This acrylic resin layer 102 acts to prevent precipitation of oligomers on the surface of the PET film 101 in processes conducted later. The acrylic resin layer 102 also serves to planarize the uneven surface of the PET film ~~[[102]]~~ 101. Generally, PET film surface has unevenness of the order of several hundreds of angstroms to 1  $\mu\text{m}$ . Such unevenness greatly affects the electrical properties of the semiconductor layer having a thickness of several hundreds of angstroms. Therefore, it is quite important to planarize the base on which the semiconductor layer is formed.